C₆H₁₀S AND C₆H₁₀S₂

Data collection

Enraf–Nonius CAD-4	$\theta_{\rm max} = 27.39^{\circ}$
diffractometer	$h = -6 \rightarrow 6$
ω -2 θ scans	$k = 0 \rightarrow 18$
Absorption correction: none	$l = 0 \rightarrow 13$
1812 measured reflections	3 standard reflections
1812 independent reflections	frequency: 30 min
1634 reflections with	intensity decay: 10%
$I > 2\sigma(I)$	

Refinement

Refinement on F^2	$(\Delta/\sigma)_{\rm max} = 0.001$
R(F) = 0.0498	$\Delta \rho_{\rm max} = 0.766 \ {\rm e} \ {\rm \AA}^{-3}$
$wR(F^2) = 0.1355$	$\Delta \rho_{\rm min} = -0.733 \ {\rm e} \ {\rm \AA}^{-3}$
S = 1.101	Extinction correction: none
1812 reflections	Scattering factors from
113 parameters	International Tables for
All H atoms refined	Crystallography (Vol. C)
$w = 1/[\sigma^2(F_o^2) + (0.1049P)^2]$	
+ 0.1396 <i>P</i>]	
where $P = (F_o^2 + 2F_c^2)/3$	

Table 3. Fractional atomic coordinates and equivalent isotropic displacement parameters $(Å^2)$ for (2)

$U_{eq} = (1/2)^{1/2}$	′3)Σ	$L_i \Sigma_j U$	^{лу} а*;	$a_i^* \mathbf{a}_i$.	a _j .
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	x	у	z	U_{eq}
C11	0.5820 (4)	0.83649 (14)	0.9424 (2)	0.0377 (4)
C12	0.5490 (5)	0.8573 (2)	1.0738 (2)	0.0440 (5)
C13	0.3679 (7)	0.9086(2)	1.1091 (3)	0.0602 (7)
C21	0.1651 (4)	0.6497 (2)	1.0875 (2)	0.0377 (4)
C22	0.3244 (4)	0.56510(14)	1.1197 (2)	0.0412 (5)
C23	0.5286 (5)	0.5670(2)	1.1986 (2)	0.0486 (5)
S1	0.53204 (8)	0.71000 (3)	0.90186 (4)	0.0336 (2)
S2	0.16519 (8)	0.68598 (4)	0.92458 (4)	0.0367 (2)

Table 4. Selected geometric parameters (Å, °) for (2)

C11—C12 C11—S1 C12—C13 C21—C22	1.483 (3) 1.830 (2) 1.295 (4) 1.475 (3)	C21—S2 C22—C23 S1—S2	1.837 (2) 1.313 (3) 2.0303 (8)
C12—C11—S1	112.97 (14)	C23—C22—C21	123.8 (2)
C13—C12—C11	124.2 (2)	C11—S1—S2	104.33 (7)
C22—C21—S2	112.84 (14)	C21—S2—S1	105.17 (7)

An absorption correction was not applied because μ was small for both compounds. A correction was applied to both compounds for 10% decay. The structures were solved by direct methods (*SHELXS86*; Sheldrick, 1990) and refined by full-matrix least squares where the quantity minimized was $[\Sigma(F_o-F_c)^2]$ (*SHELXL*93; Sheldrick, 1993). The H atoms were refined using a riding model.

For both compounds, data collection: CAD-4 Software (Enraf-Nonius, 1989); cell refinement: CAD-4 Software; data reduction: DATAP (Coppens, Leiserowitz & Rabinovich, 1965); molecular graphics: ORTEPII (Johnson, 1976).

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Tetravinylsilane

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Abstract

A single crystal of tetravinylsilane, $C_8H_{12}Si$, was grown in a capillary at low temperature using zone-melting techniques. Intensity data were collected at 95 K. The title compound crystallizes in space group *Pbca* with one molecule in the asymmetric unit.

Comment

The structure of the title compound is of interest for the synthesis of new silicon-containing materials, for example, dendrimers and polymers (Seyferth, Son, Rheingold & Ostrander, 1994). We have investigated the structure of tetravinylsilane, (I), in order to determine whether it is a suitable candidate for solid-state photochemistry (Schmidt, 1976).



Supplementary data for this paper are available from the IUCr electronic archives (Reference: AV1003). Services for accessing these data are described at the back of the journal.

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The Si atom is bonded to four C atoms which form an almost ideal tetrahedron. The C—Si—C angles are between 107.85 (6) and 111.34 (6)°. The average Si— C_{sp^2} distance of 1.860 (1) Å, as well as the C—C doublebond lengths of 1.318 (1) Å, are characteristic for unsaturated silicon-containing compounds. The molecular point group of tetravinylsilane is C_1 . However, disregarding C8, it shows a pseudo- C_3 rotation axis when viewed along the C7—Si bond. The shortest intermolecular distances found are 3.679 Å. The shortest intermolecular distances between almost parallel double bonds are 3.880 and 3.996 Å. Planes passing through these bonds form an angle of 24° with one another. The possibility of a photochemical reaction in the solid state cannot therefore be ruled out (Fig. 2).



Fig. 1. View of the title molecule showing the labeling of the non-H atoms. Displacement ellipsoids are shown at the 50% probability level.



Fig. 2. Packing of tetravinylsilane.

Experimental

Tetravinylsilane obtained from Aldrich was purified by preparative GC. The crystal used for analysis was grown by a zonemelting technique in a capillary of outer diameter 0.3 mm with a focused laser beam as heat source (Boese & Nussbaumer, 1994). Crystal data

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Data collection

Enraf–Nonius CAD-4	$\theta_{\rm max} = 27.60^{\circ}$
diffractometer	$h = 0 \rightarrow 11$
ω –2 θ scans	$k = 0 \rightarrow 12$
Absorption correction: none	$l = 0 \rightarrow 26$
2103 measured reflections	3 standard reflections
2103 independent reflections	frequency: 30 min
1787 reflections with	intensity decay: 10%
$I > 2\sigma(I)$	

Refinement

C1 C2

C3 C4 C5 C6 C7 C8

Si

Refinement on F^2	$(\Delta/\sigma)_{\rm max} = -0.001$
R(F) = 0.0399	$\Delta \rho_{\rm max} = 0.396 \ {\rm e} \ {\rm \AA}^{-3}$
$wR(F^2) = 0.1222$	$\Delta \rho_{\rm min} = -0.342 \ {\rm e} \ {\rm \AA}^{-3}$
S = 1.079	Extinction correction: none
2103 reflections	Scattering factors from
130 parameters	International Tables for
All H atoms refined	Crystallography (Vol. C)
$w = 1/[\sigma^2(F_o^2) + (0.1P)^2]$	
where $P = (F_0^2 + 2F_c^2)/3$	

Table 1. Fractional atomic coordinates and equivalent isotropic displacement parameters (Å²)

$U_{\rm eq} = (1/3) \sum_i \sum_j U^{ij} a_i^* a_i^* \mathbf{a}_i . \mathbf{a}_j.$

x	у	z	U_{eq}
0.0851 (2)	0.71623 (6)	0.38072 (12)	0.0334 (3)
0.1195 (2)	0.72815 (7)	0.25321 (14)	0.0423 (4)
0.18292 (14)	0.59506 (6)	0.53142 (13)	0.0321 (3)
0.3163 (2)	0.62131 (9)	0.54367 (15)	0.0418 (4)
-0.04221 (15)	0.58508 (6)	0.29817 (13)	0.0336 (3)
0.0251 (2)	0.53302 (7)	0.2494 (2)	0.0446 (4)
-0.13010 (15)	0.64391 (7)	0.56888 (13)	0.0327 (3)
-0.2542 (2)	0.60975 (8)	0.5686(2)	0.0389 (3)
0.02355 (4)	0.63491 (2)	0.44370 (3)	0.0244 (2)

Table 2. Selected geometric parameters (Å, °)

C1—C2	1.318(2)	C5—C6	1.316 (2)
C1—Si	1.8604 (12)	C5—Si	1.8574 (13)
C3—C4	1.320(2)	C7—C8	1.317 (2)
C3—Si	1.8624 (13)	C7—Si	1.8624 (13)
C2—C1—Si	123.64 (10)	C1—Si—C7	110.73 (6)
C4—C3—Si	124.33 (11)	C3—Si—C7	107.85 (6)
C6—C5—Si	125.46 (12)	C1—Si—C5	109.13(6)
C8C7Si	125.12 (11)	C3—Si—C5	111.34 (6)
C1—Si—C3	108.50 (6)	C7SiC5	109.29 (6)

An absorption correction was not applied because μ was small. A correction was applied for 10% decay. The structure was solved by direct methods (*SHELXS86*; Sheldrick, 1990) and refined by full-matrix least squares where the quantity minimized was $[\Sigma(F_o-F_c)^2]$ (*SHELXL*93; Sheldrick, 1993). The H atoms were refined using a riding model.

Data collection: CAD-4 Software (Enraf-Nonius, 1989). Cell refinement: CAD-4 Software. Data reduction: DATAP (Coppens, Leiserowitz & Rabinovich, 1965). Molecular graphics: ORTEPII (Johnson, 1976).

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Supplementary data for this paper are available from the IUCr electronic archives (Reference: AV1004). Services for accessing these data are described at the back of the journal.

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precursors of vegetal origin, in view of the diminishing availability of whales. The (+)-isomer of the title compound, (1), has proved to be a powerful synthetic tool for the preparation of *trans*-decalin derivatives with a strong ambergris odor (Gaitán, 1996). The title compound can be isolated by chemical resolution of the racemic mixture, which is obtained by crosssectioning the trunk of *Eperua purpurea* (De Santis & Medina, 1981). The (-)-enantiomeric constituent and the (+)-isomer are expected to have the same structural characteristics, except for their configuration. This paper reports the results of an X-ray crystal structure study of (1), carried out in order to determine the conformation and crystal packing of the molecule.



A view of the molecular structure is shown in Fig. 1. The (-)-enantiomer was chosen in accord with the high negative value for the specific optical rotation of the ethanolic solution of the crystals obtained after resolution. The C—C bond distances of the *trans*decalinic fragment of (1) are similar to those found (single-bond range 1.497–1.575 Å) in two related *trans*decalinic molecular fragments (Singh, Gray, Skelton, Waterman & White, 1991; Grant, Hanton & Wong, 1995), while the bond lengths C8—C17 [1.324 (5) Å]

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(13E)-(-)-Labda-8(17),13-dien-15-oic Acid

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Abstract

In the title compound, $C_{20}H_{32}O_2$, the two six-membered rings have a ${}^{1}C_4$ chair conformation and the rings are *trans*-fused. The crystal structure is stabilized by approximately symmetric $R_2^2(8)$ -type hydrogen bonds.

Comment

As part of our efforts towards the introduction of new starting materials for the synthesis of ambergris odorants, we have directed our attention to synthetic



Fig. 1. Molecular diagram of the title compound showing the atomnumbering scheme. Displacement ellipsoids are drawn at the 35% probability level.

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